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Citation: Appl. Phys. Lett. 113, 221102 (2018); doi: 10.1063/1.5054865
View online: https://doi.org/10.1063/1.5054865
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Published by the American Institute of Physics

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(Received 4 September 2018; accepted 8 November 2018; published online 26 November 2018)

The integration of quantum emitters with integrated photonics enables complex quantum photonic circuits that are necessary for photonic implementation of quantum simulators, computers, and networks. Thin-film lithium niobate is an ideal material substrate for quantum photonics because it can tightly confine light in small waveguides and has a strong electro-optic effect that can switch and modulate single photons at low power and high speed. However, lithium niobate lacks efficient single-photon emitters, which are essential for scalable quantum photonic circuits. We demonstrate deterministic coupling of single-photon emitters with a lithium niobate photonic chip. The emitters are composed of InAs quantum dots embedded in an InP nanobeam, which we transfer to a lithium niobate waveguide with nanoscale accuracy using a pick-and-place approach. An adiabatic taper transfers single photons emitted into the nanobeam to the lithium niobate waveguide with high efficiency. We verify the single photon nature of the emission using photon correlation measurements performed with an on-chip beamsplitter. Our results demonstrate an important step toward fast, reconfigurable quantum photonic circuits for quantum information processing. Published by AIP Publishing.

https://doi.org/10.1063/1.5054865

Thin-film lithium niobate (LiNbO3) is an emerging material platform for integrated photonics1–3 which exhibits tightly confined optical modes, a high refractive index, and a wide transmission window (350 nm to 5 μm). Moreover, this material inherits the strong $\chi^2$ electro-optic nonlinearity from LiNbO3 bulk crystals,4–6 which enables ultrafast optical modulation. The tight confinement of the optical modes in thin-film LiNbO3 significantly reduces the device size and facilitates scalable fabrication of many optical elements on a small chip. This scalability was not possible using conventional metal diffused waveguides, as they have large and loosely confined optical modes.7 Recently, researchers have realized nanophotonic structures based on thin-film LiNbO3 with low loss8–11 and a high modulation bandwidth12 competing with the metal diffusion technology but with a much smaller footprint, turning thin-film LiNbO3 into a versatile platform for integrated photonic circuits.

Strong electro-optic nonlinearity and compact nature of thin-film LiNbO3 make it an ideal platform for quantum photonic circuits that can enable optical quantum computation,13–18 high-speed quantum communications,19,20 and simulation of non-classical problems in quantum physics,21 chemistry,22 and biology.23 Many of these applications require quantum emitters that serve as both high-purity sources of indistinguishable single photons24,25 and strong optical nonlinearities at the single photon level.26,27 As a result, developing techniques for the integration of LiNbO3 photonics with quantum emitters is an effective strategy for implementing fast reconfigurable quantum circuits. However, to date, this integration has yet to be demonstrated. One of the difficulties is that conventional metal diffused LiNbO3 waveguides exhibit a small index contrast and large mode volume, which leads to poor transfer efficiencies for emitters that are embedded or evanescently coupled. However, thin-film LiNbO3 exhibits a much tighter mode confinement that could potentially solve this problem, which provides a new opportunity for quantum emitter integration.

In this letter, we demonstrate integration of quantum emitters with LiNbO3 photonic devices. The quantum emitters are InAs quantum dots embedded in an InP nanobeam, which serve as efficient sources of single photons in the telecom band.28,29 We develop a hybrid device structure that efficiently transfers the emission from the dots to a LiNbO3 waveguide. Tight confinement of the thin-film LiNbO3 waveguide enables large mode overlap between the InP nanobeam and the LiNbO3 waveguide which allows evanescent coupling30,31 with efficiency exceeding 34%. Realizing such mode overlap between a nanostructure containing quantum dots and metal diffused LiNbO3 waveguides would require a more complicated mode engineering potentially with very long adiabatic tapering. To experimentally demonstrate this approach, we fabricate a hybrid device using a pick-and-place technique based on the focused ion beam.32,33 We verify efficient transfer of single photons from the quantum dot to LiNbO3 and confirm the single-photon nature of the emission with photon correlation measurements. This approach could enable scalable integration of single-photon emitters with...
complex LiNbO$_3$ photonic circuits that can rapidly modulate the photons and perform user-defined linear optical transformations on them.

Figures 1(a) and 1(b) show the general scheme for coupling single-photon emitters with a LiNbO$_3$ waveguide. Figure 1(a) shows a cross-sectional illustration of the device which is composed of an InP nanobeam (500 nm wide and 280 nm thick) containing InAs quantum dots (with a density of $\sim 10^{10} \text{cm}^{-2}$) on top of a LiNbO$_3$ waveguide. In the design, we use a partially etched LiNbO$_3$ nanobeam with a width of 1200 nm, which ensures the single mode condition at the InAs quantum dot wavelength of $\sim 1300$ nm while maintaining a relatively large top surface area to transfer the InP nanobeams. The single photon from the quantum dot couples to the InP nanobeam and then smoothly transfers to the LiNbO$_3$ waveguide through a 5 $\mu$m adiabatic taper [Fig. 1(b)]. A Bragg reflector at one end of the nanobeam, composed of a periodic array of holes with a period of 290 nm and a radius of 100 nm, ensures that the quantum dot emission propagates in only one direction (Fig. S1 in the supplementary material).

We performed finite-difference time-domain (Lumerical) simulations to estimate the efficiency of single photon coupling from the quantum dots to the InP nanobeam and subsequently to the LiNbO$_3$ waveguide. In our simulation, we model the quantum dots as electric dipole emitters with an in-plane polarization which are located at the center of the nanobeam. Figure 1(c) displays a cross-sectional view of light propagation in the hybrid device. The simulation shows that emission from the quantum dot couples to the single mode of the InP nanobeam and then adiabatically transfers to the LiNbO$_3$ waveguide as the taper narrows down. We calculate the coupling efficiency between the InP nanobeam and LiNbO$_3$ waveguide modes for a taper length of 5 $\mu$m to be 40.1%. A longer adiabatic taper can further improve this efficiency [see Fig. S1(c) in the supplementary material]. However, for our current devices, we used a 5 $\mu$m taper length to make it easier to transfer the nanobeam onto the waveguide using the pick-and-place method described below. The total efficiency from the quantum dot to the LiNbO$_3$ waveguide mode was calculated to be 34% by multiplying the efficiency of coupling for the quantum dot to the InP mode (85%) and the efficiency of InP to LiNbO$_3$ coupling (40.1%). (See supplementary material for details.)

To fabricate the designed device, we first patterned the nanobeam and LiNbO$_3$ waveguide on separate substrates and then transferred the nanobeam to the waveguide using a pick-and-place technique we previously developed. The substrate for the LiNbO$_3$ waveguides was a 600 nm thick X-cut LiNbO$_3$ film on 2 $\mu$m thick silicon dioxide (SiO$_2$) and a silicon substrate (NanoLN). We patterned the photonic structures by electron beam lithography using an HSQ resist. Next, we transferred the patterns onto a LiNbO$_3$ thin film using an optimized Ar+ plasma etching recipe in a reactive ion etching tool. Finally, we removed the residual mask by buffered oxide etching. Figure 2(a) shows the fabricated waveguide structure and y-branch 50:50 beamsplitter. We terminated the waveguides with a periodic grating coupler with a period of 700 nm at one end of the structure for outcoupling the single-photon emission, with a calculated efficiency of 26.7% (see Fig. S2 in the supplementary material for the design of the gratings).

To create the InP waveguides, we began with a substrate composed of 280 nm InP on a 2 $\mu$m thick AlInAs sacrificial layer. We patterned the nanobeam device using electron beam lithography followed by inductively coupled plasma reactive ion etching and used a chemical wet etch ($\text{H}_2\text{O}/\text{HCl}$/

![FIG. 1.](a) An illustration of the hybrid platform consisting of the LiNbO$_3$ waveguide and the InAs quantum dot embedded in an InP nanobeam. (b) A side schematic of the hybrid device, showing the Bragg reflector on one side of the InP nanobeam and the adiabatic taper on the other side. (c) Finite-difference time-domain simulation of the electric field intensity $|E_j|^2$ in the coupling area. Yellow and white solid lines represent the boundaries of the InP nanobeam and LiNbO$_3$ waveguide, respectively. The dashed yellow lines indicate the boundary of the tapered region of the nanobeam.

![FIG. 2.](a) SEM image of the LiNbO$_3$ straight waveguide and y-branch beamsplitter. The rectangular pads on the left end of the LiNbO$_3$ waveguides assist in the transfer process. Periodic grating couplers on the right side of the devices extract the light from the LiNbO$_3$ waveguides. (b) SEM image of the suspended InP nanobeam. (c) The InP nanobeam attaches to the microprobe tip by van der Waals forces. (d) False color SEM image of the integrated InP nanobeam with a straight LiNbO$_3$ waveguide. (e) False color SEM image of the integrated InP nanobeam with an on-chip LiNbO$_3$ beamsplitter. Red and blue colors indicate InP and LiNbO$_3$, respectively. The scale bar is 6 $\mu$m in all panels.)
H$_2$O$_2$ = 3:1:1) to remove the sacrificial layer, leaving a suspended nanobeam. Figure 2(b) displays a scanning electron microscopy (SEM) image of the suspended InP nanobeam. The square pad at one end of the nanobeam facilitates the pick-and-place procedure. By contacting the pad with a microprobe tip and cutting the remaining InP tethers with the focused ion beam, we release the nanobeam from the substrate [Fig. 2(c)] and place it on a previously fabricated LiNbO$_3$ straight waveguide [Fig. 2(d)] or beamsplitter [Fig. 2(e)].

To characterize the fabricated devices, we performed optical measurements using a low-temperature micro-photoluminescence setup operated at 4 K (see supplementary material). We excited the quantum dots with a 780 nm continuous wave laser and collected the photoluminescence output through the grating coupler [inset of Fig. 3(a)]. Figure 3(a) shows the photoluminescence spectrum taken from the straight LiNbO$_3$ waveguide. We observed multiple emission lines in the photoluminescence spectrum that confirmed the coupling of multiple spectrally resolved quantum dots. To assess the photon collection efficiency in our hybrid device, we used a 785 nm pulsed laser excitation with a repetition rate of 40 MHz. Correcting for our setup efficiency, we calculated a collection efficiency of 2.2% at the first lens for a representative coupled quantum dot labeled as QD1 in Fig. 3(a) (see supplementary material). This value is lower than the ideal collection efficiency of 9% which we determined from our simulations. The simulated collection efficiency is the product of the coupling efficiency from the quantum dot to LiNbO$_3$ (34%) and the grating coupler efficiency (26.7%). We attribute the lower experimental collection efficiency to small fabrication imperfections (Fig. S2 in the supplementary material), residual misalignment of the nanobeam with the LiNbO$_3$ waveguide, and quantum dot deviations from the center of the nanobeam.

To confirm the single photon nature of the emission, we performed second order photon correlation measurements on several of the coupled quantum dot emission lines. In this setup, we sent the collected signal through the grating coupler to a fiber beamsplitter and connected the two output ports of the beamsplitter to different single-photon detectors. Figure 3(b) shows a continuous wave second-order correlation measurement for QD1, using a 780 nm laser. The measurement shows a clear antibunching behavior. We fit the antibunching dip to a function of the form $g^{(2)}(\tau) = 1 - (1 - g^{(2)}(0)) \exp\left(-|\tau|/\tau_0\right)$ without dark count subtraction or deconvolution and obtained $g^{(2)}(0) = 0.08$, which is lower than the classical limit of 0.5. Background emissions due to our non-resonant excitation cause the residual multiphoton events, resulting in non-ideal $g^{(2)}(0)$ values in our photon correlation measurements. Resonant excitation$^{35,36}$ or quasi-resonant excitation$^{37,38}$ could significantly improve the purity of the single photons by reducing the background emissions.

Next, we investigated the hybrid device in Fig. 2(e) which integrates quantum dots in the InP nanobeam with an on-chip LiNbO$_3$ beamsplitter. We excited the quantum dots directly from the top of the nanobeam and collected the photoluminescence signal from both grating couplers [insets of Figs. 4(a) and 4(b)]. We separated the signal from each grating using a pick-off mirror in free space and sent each port to separate spectrometers that acted as spectral filters. Figures 4(a) and 4(b) show the collected photoluminescence signal from the top and bottom gratings. We observed multiple quantum dot lines in both spectra. We identified 7 emission lines that appear in both spectra, suggesting that they originate from the same quantum dots.

To confirm that the replicated emission lines in Figs. 4(a) and 4(b) originate from the same quantum dot, we performed a photon correlation measurement on the quantum dot represented by line 4 and spectrally filtered out all other emission lines (see Fig. S3 in the supplementary material for a schematic of the measurement setup). Figure 4(c) shows the second-order photon correlation measurement of this emission using continuous wave excitation, with $g^{(2)}(0) = 0.36$. The measured $g^{(2)}(0)$ value is degraded as compared to the measurement in Fig. 3(b). This degradation is due to the fact that the device with an on-chip beamsplitter exhibited a poorer coupling efficiency, which required higher excitation power in order to obtain a second-order correlation. This higher excitation drove the quantum dot closer to the saturation level, resulting in a higher background level. This measurement demonstrates that the two matched lines from the grating couplers originate from the same quantum dot. The on-chip LiNbO$_3$ beamsplitter enables the direct measurement of a second-order photon correlation from the quantum dots coupled to the LiNbO$_3$ waveguide without an external beamsplitter. Implementing this functionality on-chip is a step toward scalable integration of multiple single-photon emitters with more complex LiNbO$_3$ photonic circuits, where most of the light manipulations happen on a compact photonic chip.
tor based electro-optic switches would allow fast switching.

In summary, we have deterministically coupled quantum emitters to a nanophotonic LiNbO$_3$ waveguide. We confirmed the coupling of single photons to straight waveguides and y-branch beamsplitters using photon correlation measurements. The collection efficiency of our devices was limited by the performance of the grating couplers. More efficient grating coupler design or better approaches of light collection, such as edge coupling, tapered fibers, or the incorporation of detectors on the chip, could boost the collection efficiency. Incorporation of Mach-Zehnder or resonator based electro-optic switches would allow fast switching of single photons. Moreover, by pre-characterizing the quantum dot devices before pick-and-place, we can overcome the spectral and spatial randomness of the quantum dots and select the devices with emitters at the same resonance wavelength. In this way, we can efficiently extend our results to complex LiNbO$_3$ circuits containing many identical single-photon emitters. Our results represent an important step toward routing and fast feedforwarding of on-demand single photons on a chip, which could enable high speed quantum communication and linear optical approaches for photonic quantum computing.

See supplementary material for additional finite-difference time-domain simulation provided for the taper coupling efficiency, Bragg mirror geometry, and design and simulation of the grating couplers. Also, this file includes details on the measurement setup and estimation of the quantum dot collection efficiency.

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The authors would like to acknowledge support from the Center for Distributed Quantum Information at the University of Maryland and Army Research Laboratory and the Physics Frontier Center at the Joint Quantum Institute. Lithium niobate devices were fabricated at the Center for Nanoscale Systems (CNS) at Harvard, a member of the National Nanotechnology Infrastructure Network, supported by the NSF.